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Scientific paper

ISSN 0351-9465, E-ISSN 2466-2585

<https://doi.org/10.62638/ZasMat1668>



Zastita Materijala 67 ( )  
(2026)

## The impact of plasma nitriding bias voltages on mechanical characteristics of 25Cr2Ni4W steel

### ABSTRACT

*This study investigates the influence of negative bias voltage on the plasma nitriding behavior of 25Cr2Ni4W low-alloy steel to enhance its surface mechanical and tribological performance. The bias voltage was systematically varied from 2.0 to 3.5 kV, while discharge power, pressure, and treatment time were kept constant. Substrate heating was achieved through a self-induced mechanism. X-ray diffraction (XRD) analysis confirmed the formation of a compound layer consisting of  $\epsilon$ -Fe<sub>2-3</sub>N and  $\gamma$ '-Fe<sub>4</sub>N phases. With increasing bias voltage, a progressive transformation toward the  $\gamma$ '-Fe<sub>4</sub>N phase was observed, accompanied by a reduction in  $\epsilon$ -Fe<sub>2-3</sub>N content. This microstructural evolution significantly affected surface mechanical properties. Nanoindentation results revealed a marked increase in hardness compared with the untreated substrate. The sample treated at 2.0 kV (CW1) exhibited the highest and most stable nanohardness ( $\approx$  6000 MPa), indicating a dense and coherent nitride layer. Conversely, the 3.5 kV (CW4) condition yielded a lower nanohardness ( $\approx$  4000 MPa) due to excessive sputtering and reduced nitrogen diffusion. These results demonstrate that accurate control of negative bias voltage is a key factor in tailoring the nitride phase composition and optimizing surface hardening in plasma-nitrided 25Cr2Ni4W steel.*

**Key words:** Plasma nitriding, Low alloy steel, Nitride phases, Nano-hardness

### 1. INTRODUCTION

The mechanical performance of engineering alloys is strongly influenced by both bulk composition and surface condition. Among these alloys, the low-alloy steel 25Cr2Ni4W has been widely adopted in the manufacturing of pipes, railroad tracks, automobile and aircraft bodies, as well as in onshore and offshore structural engineering, owing to its high strength and toughness. Alloying elements such as chromium, molybdenum, and vanadium contribute to enhanced hardenability, corrosion resistance, and fatigue strength. [1].

However, despite these advantages, 25Cr2Ni4W may still experience performance limitations under severe wear, cyclic loading, or impact conditions [2] [3]. These challenges have motivated the development and application of advanced surface engineering techniques to further improve its service life and reliability [4].

Thermochemical surface treatments are widely applied to extend component life by improving hardness [5], wear resistance, and fatigue strength [6-8]. Plasma nitriding (ion nitriding) is particularly effective because it forms hardened surface layers while preserving the material's core properties [9,10]. Owing to this balance, it is extensively used in the automotive, aerospace, and tooling industries [11,12].

Plasma nitriding relies on the diffusion of nitrogen into the metallic substrate at temperatures between 350–600 °C, forming a hardened compound layer and diffusion zone [13,14]. This process increases fatigue resistance and wear performance while allowing for controlled property tailoring [15].

The treatment is performed in a low-pressure chamber containing nitrogen-based gases such as ammonia or nitrogen–hydrogen mixtures. An electrical discharge generates plasma, ionizing the gas [16]. The positively charged nitrogen ions are accelerated toward the negatively biased specimen surface, where they are absorbed and diffuse into the lattice [17,18]. Despite its advantages of uniformity and precision, plasma nitriding requires careful process control to avoid excessive brittleness [19].

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Paper received: 12.12.2025.

Paper corrected: 24.02.2026.

Paper accepted: 28.03.2026.

Nitrogen uptake during treatment occurs via sputtering, adsorption, and diffusion, leading to the formation of a compound (white) layer and a diffusion zone [20,21]. These modified layers significantly affect mechanical behavior, particularly fracture toughness and impact resistance [22]. Optimizing the treatment parameters is therefore critical for achieving the desired property balance [23].

This study examines the influence of plasma nitriding on the impact toughness of Charpy test specimens. [24,25]. By correlating nitriding parameters such as temperature, duration, and gas composition with impact energy absorption [26]. This work provides new insights into the relationship between surface hardening and toughness [27]. These findings are especially relevant to applications where components must withstand sudden impact and cyclic stresses [28].

## 2. EXPERIMENTAL PART

### 2.1. Materials

The chemical composition of this low-alloy steel is presented in Table 1. The presence of nickel and chromium enhances the tensile strength, wear resistance, and ductility of 25Cr2Ni4W, while manganese improves its hardenability [29].

Table 1. Chemical composition of low-alloyed steel

Element s	C %	Mn	Cr	Ni	W	P	S
Wt[%]	0.2 8	0.5	1.5	3.9 7	0.7 3	0.0 2	0.0 1

In this study, cylindrical samples of 25Cr2Ni4W (diameter: 22 mm, thickness: 10 mm) were supplied by ECMK Company located in Khenchela-Algeria. Prior to treatment, the flat surfaces were mirror-polished using SiC sandpapers with grit sizes of 180, 320, 600, 800, 1000, and 1400 in sequential order (Struers, Ballerup, Denmark).

Subsequently, the samples were further polishing using a disk polishing machine with a 3  $\mu$ m diamond paste (Struers, Ballerup, Denmark). Finally, a chemical etching process was performed using a solution of 4% nitric acid (Sigma-Aldrich, St. Louis, MO, USA) in 96% ethanol (Merck, Darmstadt, Germany) to thoroughly cleanse the samples and remove any residual contaminants.

### 2.2. Plasma nitriding processing

The plasma nitriding experiments were carried out in a spherical chamber with a diameter of 930 mm, equipped with a vacuum system capable of achieving a base pressure of  $10^{-3}$  mTorr. Initial evacuation was performed using a primary pump reaching  $\sim 1$  mTorr, followed by a secondary oil

diffusion pump to obtain the higher vacuum level. An inductively coupled plasma (ICP) source, fabricated in-house, was energized by a 13.56 MHz RF generator through a surrounding copper coil.



Figure 1. System of plasma nitriding

The ICP source measures 170 mm in length, 100 mm in diameter, and 5 mm in thickness. Samples were mounted on a 1500 mm long, 13 mm diameter quartz substrate holder, chosen for its insulating properties to minimize electrical breakdown and arcing under DC bias. A high-voltage DC power supply (model HCN 2800–6500, CDTA Laboratory, Algiers, Algeria) was used to bias the specimens at 400 mA/6.5 kV or higher. The sample-to-plasma source distance was fixed at 100 mm in all treatments to ensure uniform surface modification. As shown in Table 2, three specimens (CW1, CW2, and CW3) were plasma nitrided under identical treatment conditions of discharge power (200 W), chamber pressure (60 mTorr), and duration (90 min).

Table 2. Experimental parameters

Samples	Parameters
CW1	Biased voltage <b>2.0 kV</b> , Discharge power = 200 W Pressure = 60 mTorr t = 90 min
CW2	Biased voltage <b>2.5 kV</b> , Discharge power = 200W Pressure = 60 mTorr t = 90 min
CW3	Biased voltage <b>3.0 kV</b> , Discharge power = 200W Pressure = 60 mTorr t = 90 min
CW4	Biased voltage <b>3.5KV</b> , Discharge power = 200 W Pressure = 60 mTorr t = 90min

The only variable parameter was the applied negative bias voltage, which was set to 2.0 kV, 3.0 kV, and 3.5 kV for CW1, CW2, and CW3, respectively. This experimental design isolates the effect of bias voltage on nitrogen ion bombardment energy, thereby influencing nitrogen uptake, diffusion depth, and the formation of the nitrated layer. Consequently, a comparative analysis of the three samples provides insight into the relationship between ion acceleration energy and the resulting mechanical and microstructural properties of the treated material.

### 3. RESULTS AND DISCUSSION

#### 3.1 X-ray diffraction analysis

Figure 2 presents the XRD diffractograms of the developed samples. For the CW1 sample, exposed to a polarization voltage of 2.0 kV, three peaks at 40.3°, 44.9°, and 81.75° can be identified. The first peak is associated with  $\epsilon$ -Fe<sub>2-3</sub>N, while the remaining peaks can be assigned to  $\alpha$ -Fe. The XRD diffractograms of the samples treated at 3.0 kV and 3.5 kV still exhibit peaks related to these phases, but the intensity of the peak at 44.9° has significantly decreased.

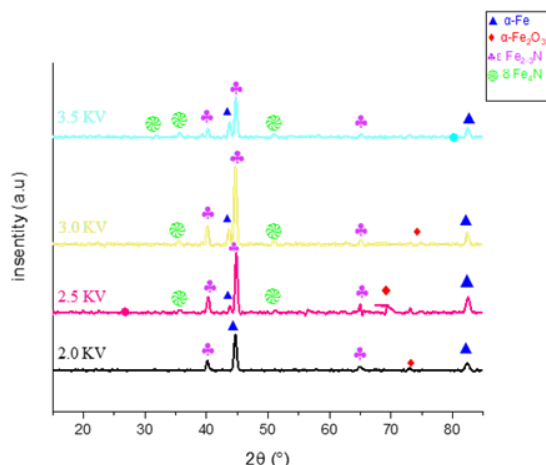


Figure 2. XRD diffraction patterns of CW1, CW2 and CW3 samples.

The  $\gamma$ '-Fe<sub>4</sub>N phase has been identified as the source of the weak peaks, located approximately at 35.7° and 51.8°, in the XRD diagram of the sample treated at 3.0 kV, CW2. Additionally, another weak-intensity peak appears at 65.6°, attributed to the  $\epsilon$ -Fe<sub>2-3</sub>N phase. According to Vegard's law [27], this is likely due to a reduction in nitrogen content, modifying the lattice parameter of the  $\epsilon$ -Fe<sub>2-3</sub>N phase. A low-intensity peak at 58.7° for the 3.5 kV-treated sample, CW3, is identified and associated with the  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> phase. These observations can be explained by greater self-heating at 3.5 kV compared to 3.0 kV, leading to enhanced nitrogen

diffusion but a lower nitrogen concentration in the treated layers of the sample. The presence of the  $\gamma$ '-Fe<sub>4</sub>N phase at 3.5 kV can be attributed to diffusion phenomena, resulting in increased nitrogen penetration. These findings are consistent with the binary phase diagram of the Fe-N system [28], indicating the presence of the  $\epsilon$ -Fe<sub>2-3</sub>N and  $\gamma$ '-Fe<sub>4</sub>N phases.

The crystallite size was estimated from the XRD patterns using the Scherrer equation:

$$D = \frac{K\lambda}{\beta \cdot \cos \theta}$$

In the table 3 the results reveal a clear dependence on the applied bias voltage during plasma nitriding.

Table 3. The Crystallite size of the three treated samples

Sample ID	Peak Position (2θ, °)	FWHM (β, rad)	Crystallite Size, D (nm)
CW1	40.17842	0.40465	21.85
	44.70079	0.42984	20.89
	64.99936	0.54973	17.91
	73.06546	0.43035	24.01
	82.4015	0.58467	18.88
<b>D moy = 20.7</b>			
CW2	35.7067	0.45975	18.98
	40.28501	0.39186	22.57
	42.16998	0.34802	25.57
	44.84471	0.39062	23.00
	51.21551	0.41668	22.10
	64.96174	0.25376	38.79
	69.6938	0.6604	15.32
82.52233	0.59849	18.46	
<b>D moy = 23.1</b>			
CW3	35.45618	0.39669	21.98
	40.1710	0.37298	23.71
	43.67256	0.38056	23.51
	44.70088	0.40489	22.17
	51.00606	0.42115	21.85
	65.07635	0.36353	27.10
	73.09938	0.34741	29.75
	82.44559	0.47556	23.21
	<b>D moy = 24.16</b>		
CW4	31.927	0.27958	30.89
	35.65299	0.41045	21.25
	40.24958	0.32835	26.93
	43.76197	0.40573	22.06
	44.79635	0.39436	22.77
	50.98864	0.4132	22.26
	65.13064	0.37369	26.37
	82.518140	0.47564	23.22
	<b>D moy = 24.46</b>		

At 2.0 kV, the crystallite sizes are relatively small, ranging from 22 to 29 nm, with an average of 24.68 nm, indicating limited grain growth and a predominantly fine microstructure. At 3.0 kV, crystallite sizes increase to 36–49 nm (average 41.21 nm), suggesting enhanced nitrogen diffusion and crystallite coalescence. The effect is most pronounced at 3.5 kV, where crystallite sizes range from 29 to 90 nm (average 57.54 nm), reflecting substantial grain growth under high-energy ion bombardment. This progressive increase in crystallite size with bias voltage highlights the strong influence of processing parameters on microstructural evolution: while low voltages preserve fine grains beneficial for hardness, higher voltages favor larger crystallites that may improve toughness but reduce surface hardness uniformity.

Figure 3 illustrates the evolution of indentation hardness as a function of cycle number for plasma-nitrided 25Cr2Ni4W steel treated under different bias voltages (CW1–CW4). All samples exhibit a rapid hardness increase during the first few cycles, corresponding to strain accumulation and work hardening at the surface due to cyclic plastic deformation. Thereafter, the hardness stabilizes, indicating a dynamic equilibrium between dislocation generation and recovery mechanisms within the nitrided layer.

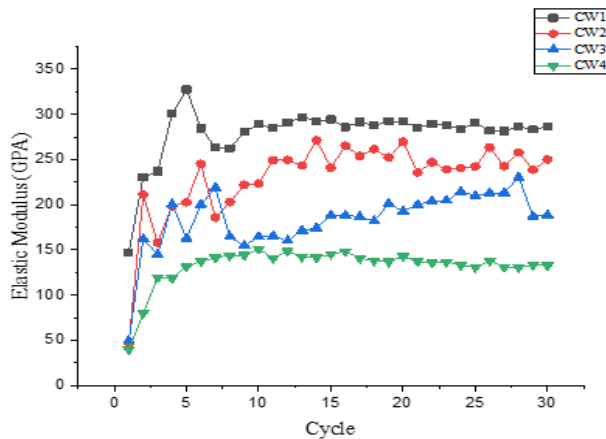


Figure 3. the evolution of indentation hardness as a function of cycle number.

The CW1 specimen, processed at the lowest bias voltage, presents the highest and most stable hardness values ( $\approx 6000$  MPa), suggesting the development of a dense and fine nitride structure with uniform nitrogen diffusion. This behavior reflects the dominance of coherent  $\gamma'-Fe<sub>4</sub>N and  $\epsilon$ -Fe<sub>2-3</sub>N phases that effectively impede dislocation motion.$

CW2 and CW3, treated at intermediate voltages, show slightly reduced hardness ( $\approx 5500$

MPa and  $\approx 5000$  MPa, respectively) and minor cyclic fluctuations associated with localized stress relaxation and microstructural rearrangement.

Conversely, CW4, subjected to the highest bias voltage, displays the lowest hardness ( $\sim 4000$  MPa) and rapid stabilization. This reduction is attributed to excessive thermal effects causing grain coarsening and possible nitride over-saturation, which diminish matrix coherence and mechanical integrity.

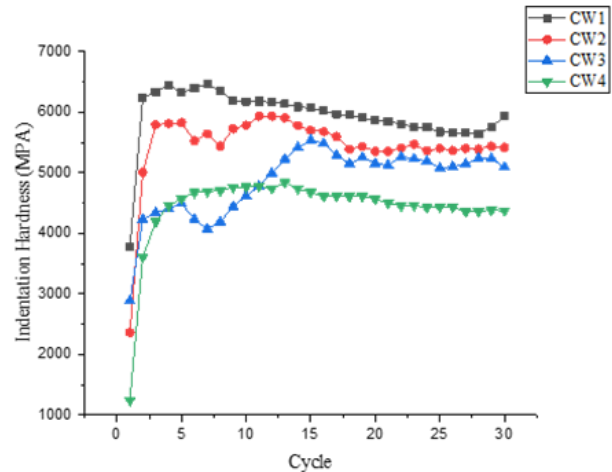


Figure 4. The variation of elastic modulus as a function of cycle number.

Figure 4 illustrates the variation of elastic modulus as a function of cycle number for plasma-nitrided 25Cr2Ni4W steel treated under different bias voltages (CW1–CW4).

The CW1 specimen, treated at the lowest bias voltage, achieves the highest modulus ( $\sim 320$  GPa), signifying a dense and coherent nitride structure that enhances elastic recovery. CW2 and CW3 show slightly lower moduli ( $\sim 280$  GPa and  $\sim 240$  GPa, respectively), suggesting moderate lattice distortions and residual stress relaxation due to increased ion bombardment energy. Conversely, CW4, processed at the highest bias voltage, displays the lowest modulus ( $\sim 200$  GPa) and rapid stabilization, indicating microstructural coarsening and reduced lattice coherence caused by excessive thermal exposure.

These results confirm that increasing bias voltage beyond an optimal range adversely affects the elastic rigidity of the nitrided layer. Controlled bias conditions therefore favor the formation of fine, defect-free nitride phases, improving the elastic and mechanical stability of plasma-nitrided 25Cr2Ni4W steel.

Figure 5 presents the variation of elastic energy with the number of cycles for plasma-nitrided 25Cr2Ni4W steel treated under different bias

voltages (CW1–CW4). A progressive increase in elastic energy is observed for all specimens, reflecting the accumulation of recoverable strain energy as the surface layer undergoes repeated elastic–plastic deformation. This trend signifies the enhancement of energy absorption capability due to cyclic stress-induced hardening.

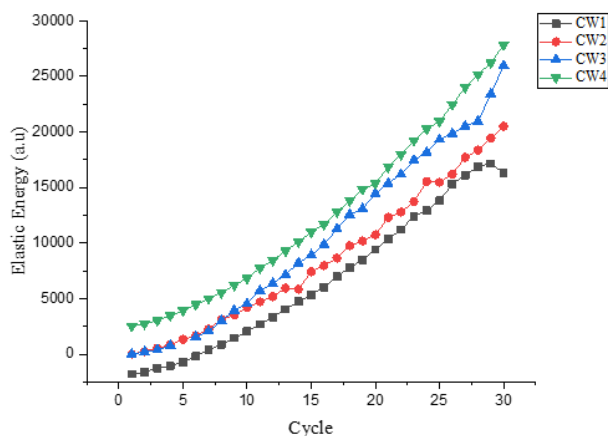


Figure 5. The variation of elastic energy with the number of cycles number.

Among the tested samples, CW4 processed under the highest bias voltage—exhibits the greatest elastic energy accumulation, reaching nearly 28,000 a.u. after 30 cycles. This behavior indicates a thicker diffusion zone and higher strain accommodation capacity, despite its lower hardness. CW3 and CW2 follow with intermediate values, while CW1, treated at the lowest bias voltage, shows the smallest energy accumulation, consistent with its more rigid and less deformable surface layer.

The gradual divergence among the curves suggests that higher bias voltages promote increased lattice strain and dislocation mobility within the nitrided region. However, excessive bias may also induce structural relaxation and microcrack initiation at longer cycles. Overall, the elastic energy evolution confirms that increasing bias voltage enhances the capacity of the nitrided layer to store and dissipate mechanical energy, up to an optimal level beyond which surface degradation may occur.

Figure 6 illustrates the evolution of plastic energy accumulation as a function of cycle number for plasma-nitrided 25Cr2Ni4W steel treated under distinct DC bias voltages: CW1 (2.0 kV), CW2 (2.5 kV), CW3 (3.0 kV), and CW4 (3.5 kV). A pronounced and direct correlation is observed between increasing bias voltage and the exponential growth of accumulated plastic energy, indicating that higher electric fields substantially intensify fatigue-induced plastic deformation.

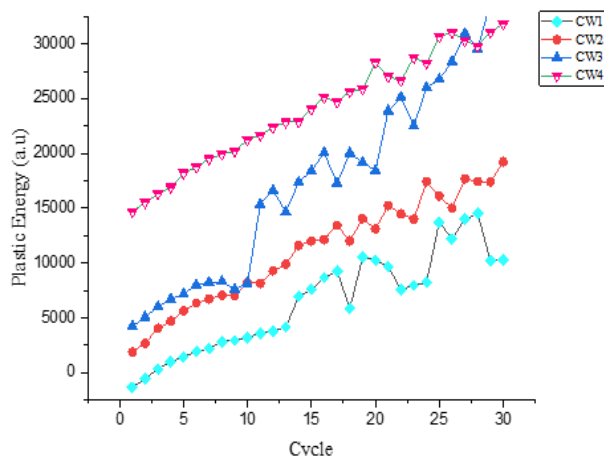


Figure 6. The evolution of plastic energy accumulation as a function of cycle number.

At lower voltages (2.0–2.5 kV), the plastic energy in CW1 and CW2 increases gradually, reflecting intermittent deformation mechanisms such as microcrack initiation, slip band evolution, or localized dislocation activity that activate only beyond specific energy thresholds. Conversely, at higher voltages (3.0–3.5 kV), specimens CW3 and CW4 exhibit markedly greater plastic energy accumulation, with CW4 displaying an almost linear, high-rate increase—characteristic of accelerated, continuous damage evolution. This suggests that elevated bias voltages enhance atomic mobility and reduce the activation barrier for dislocation motion, leading to intensified plastic flow and early fatigue damage.

#### 4. CONCLUSIONS

The present study demonstrates that plasma nitriding is an effective method for improving the surface integrity of 25Cr2Ni4W low-alloy steel. The variation in negative bias voltage strongly influences the phase composition, microstructure, and mechanical response. XRD and nanoindentation analyses revealed that applying a lower bias voltage of 2.0 kV produces a dense and coherent nitride layer dominated by  $\gamma'$ -Fe<sub>4</sub>N, resulting in the highest nanohardness (~6000 MPa) and elastic modulus (~320 GPa). In contrast, excessive ion energy at 3.5 kV promotes microstructural coarsening and reduces both hardness and modulus due to over-sputtering and thermal effects. The elastic–plastic energy analysis further confirmed that higher bias voltages enhance energy absorption but increase plastic deformation and potential fatigue susceptibility.

In addition, the formation of a compound layer consisting of  $\epsilon$ -Fe<sub>2-3</sub>N and  $\gamma'$ -Fe<sub>4</sub>N phases may also significantly influence the corrosion resistance

of the treated steel, although this aspect was not investigated in the present work.

Overall, these results highlight that maintaining a moderate negative bias voltage is essential for achieving optimal mechanical stability and surface hardening. Future investigations should focus on refining plasma parameters, exploring alternative alloy systems, and evaluating both the long-term tribological performance and corrosion behavior of nitrided components under actual service conditions.

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## IZVOD

### UTICAJ NAPONA PREDNAPONA PLAZMA NITRIRANJA NA MEHANIČKE KARAKTERISTIKE ČELIKA 25Cr2Ni4W

Ova studija istražuje uticaj negativnog napona prednapona na ponašanje plazma nitiranja niskolegiraniog čelika 25Cr2Ni4W kako bi se poboljšale njegove površinske mehaničke i tribološke performanse. Napon prednapona je sistematski varirao od 2,0 do 3,5 kV, dok su snaga pražnjenja, pritisak i vreme obrade održavani konstantnim. Zagrevanje podloge je postignuto samoindukovanim mehanizmom. Analiza rendgenske difrakcije (XRD) potvrdila je formiranje složenog sloja koji se sastoji od faza  $\epsilon$ -Fe<sub>2-3</sub>N i  $\gamma'$ -Fe<sub>4</sub>N. Sa povećanjem napona prednapona, primećena je progresivna transformacija ka fazi  $\gamma'$ -Fe<sub>4</sub>N, praćena smanjenjem sadržaja  $\epsilon$ -Fe<sub>2-3</sub>N. Ova mikrostrukturalna evolucija značajno je uticala na mehanička svojstva površine. Rezultati nanoindentacije otkrili su značajno povećanje tvrdoće u poređenju sa neobrađenom podlogom. Uzorak tretiran na 2,0 kV (CW1) pokazao je najveću i najstabilniju nanotvrdoću ( $\approx$  6000 MPa), što ukazuje na gust i koherentan nitridni sloj. Nasuprot tome, uslov od 3,5 kV (CW4) dao je nižu nanotvrdoću ( $\approx$  4000 MPa) zbog prekomernog raspršivanja i smanjene difuzije azota. Ovi rezultati pokazuju da je precizna kontrola negativnog napona prednapona ključni faktor u prilagođavanju sastava nitridne faze i optimizaciji površinskog očvršćavanja plazma nitridiranog čelika 25Cr2Ni4W.

**Ključne reči:** Plazma nitiranje, niskolegirani čelik, nitridne faze, nanotvrdoća

Naučni rad

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